

**REMARKS/ARGUMENTS**

The Examiner is thanked for the thorough examination and search of the subject.

5           Claims 163-208 are pending; Claims 163-165, 168, 171-181, 184, 187-189,  
194-201 and 205-208 have been currently amended; Claims 1-162 have been canceled.  
No new matter is believed to have been added.

Response to Claim Rejections under 35 U.S.C. 112

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*Reconsiderations of Claims 163-178 rejected under 35 U.S.C. 112, first paragraph,  
as failing to comply with the written description requirement are requested based on the  
following remarks.*

15           The Examiner considers that “There is no original basis for claiming first, second  
and third polymers. Polymer is only mentioned for first and second filling layers and the  
second filling layer is not the equivalent of the second and third polymer layers of claim  
163 or the second polymer layer of claims 179 and 197. “Polymer” is generic and there is  
no original basis for either equating the filling layers to the interlevel dielectric layers  
20 comprising “second” and “third” dielectric layers comprising “PI, BCB, porous dielectric  
material, stress buffer material, or the like”, or expanding the disclosed interlevel  
dielectric layers to “polymer”. “Polymer” is generic and broader and has no original  
basis here. All claims are dependent on new matter and are rejected.” ~ See lines 5-13  
in the last paragraph, in the last Office Action mailed Jun. 17, 2008 ~

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Applicants respectfully traverse the Examiner’s opinion because PI and BCB are a  
kind of polymer material and therefore, the interlevel dielectric layers, such as PI or BCB,  
can be deemed as a polymer layer. The subject matter that “the interlevel dielectric

layers are polymer layers” is believed to have an original basis.

Response to Claim Rejections under 35 U.S.C. 103

5           Applicants respectfully traverse the rejections for at least the reasons set forth below.

**Response to Claims 163-178**

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          As currently amended, independent claim 163 is recited below:

          163. A chip package comprising:

                  a first polymer layer;

                  a die between a first portion of said first polymer layer and a second portion

15       of said first polymer layer, wherein said die has a top surface substantially coplanar with a top surface of said first portion and with a top surface of said second portion;

                  a second polymer layer on said top surface of said die and on said top surfaces of said first and second portions;

                  a first patterned metal layer over said second polymer layer, over said top

20       surface of said die and over said top surfaces of said first and second portions, wherein said first patterned metal layer is connected to said die through an opening in said second polymer layer, wherein said first patterned metal layer comprises electroplated copper, and wherein said first patterned metal layer comprises at least a part of a passive device comprising a portion directly over said top surface of said

25       first portion;

                  a third polymer layer on said first patterned metal layer, over said second polymer layer, over said top surface of said die and over said top surfaces of said first and second portions; and

a metal bump directly over said top surface of said first portion, wherein  
said metal bump is connected to said die through said first patterned metal layer.

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5        *Reconsiderations of Claims 163-178 rejected under 35 U.S.C. 103(a) as being  
unpatentable over Eichelberger et al. (U.S. Pat. No. 6,396,148) in view of Wagner et al.  
(U.S. Pat. No. 5,196,377) and Wachtler et al. (U.S. Pat. No. 6,707,124) are requested  
based on the following remarks.*

10       Applicants respectfully assert that the chip package currently claimed in Claim 163  
patentably distinguishes over the citations by Eichelberger et al. (U.S. Pat. No. 6,396,148)  
in view of Wagner et al. (U.S. Pat. No. 5,196,377) and Wachtler et al. (U.S. Pat. No.  
6,707,124).

15       The Examiner considers that “applicant’s argument regarding “electroplated  
copper” is unconvincing of patentability. Again it is emphasized there are no specific  
copper structural differences claimed to distinguish the claimed copper over the copper of  
the applied art.” ~ See lines 16-19, on page 3, in the last Office Action mailed Jun. 17,  
2008 ~

20       Applicants respectfully traverse the Examiner’s opinion because “electroplated  
copper” can be expected to impart distinctive structural characteristics to the final product  
in the grain size using a TEM cross-section or in the crystal orientation using a TEM  
cross-section or an X-ray diffraction analysis. Furthermore, another structural feature  
25       that an electroplated copper layer is on or over an electroplating seed layer can be  
checked.

The Examiner considers that “There is no need to insert any features from one

reference into another to show obviousness.” ~ *See lines 4 and 5 on page 4, in the last Office Action mailed Jun. 17, 2008 ~*

5 Applicants respectfully traverse the Examiner’s opinion because there is believed to be a need of a test trying whether a feature from one reference is analogously inserted or incorporated into another feature from another reference based on the knowledge of one skilled in the art. Typically, analogous prima-facie cases are needed to support obvious rejection, with the explanation why the combination of these prima-facie cases is obvious by one skilled in the art.

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The Examiner considers that “Regarding polymer interlevel dielectric layers, the prior art discloses polymer interlevel dielectrics, and again, insertion of one reference onto another is not required to show obviousness. For low capacitance and absent unexpected results, it would have been obvious to substitute one interlevel dielectric material (polymer) for another known equivalent (oxide) as suggested by the applied art.”  
15 ~ *See lines 6-10 on page 4, in the last Office Action mailed Jun. 17, 2008 ~*

Applicants respectfully traverse the Examiner’s opinion because there is believed to be a need of a test trying whether a feature from one reference is analogously inserted or incorporated into another feature from another reference based on the knowledge of one skilled in the art. Furthermore, the Examiner fails to show the exact description that one interlevel dielectric material (polymer) can be substituted for another known equivalent (oxide), in the applied art referred to by the Examiner.

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25 Furthermore, all of Eichelberger et al., Wagner et al. and Wachtler et al. fail to teach, hint or suggest that a patterned metal layer over two portions of a polymer layer and over a die between the two portions may comprise at least a part of a passive device comprising a portion directly over one of the two portions, as currently claimed in Claim

163.

For at least the foregoing reasons, withdrawal of rejection under 35 U.S.C. 103(a) to Claim 163 is respectfully requested.

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Applicants respectfully submit independent Claim 163 patently distinguishes over the prior art references, and should be allowed. For at least the same reasons, dependent Claims 164-178 patently define over the prior art as well.

10 **Response to Claims 179-196**

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As currently amended, independent Claim 179 is recited below:

179. A chip package comprising:

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a first polymer layer;

a die between a first portion of said first polymer layer and a second portion of said first polymer layer, wherein said die has a top surface substantially coplanar with a top surface of said first portion and with a top surface of said second portion;

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a second polymer layer on said top surface of said die and on said top surfaces of said first and second portions;

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a patterned metal layer over said second polymer layer, over said top surface of said die and over said top surfaces of said first and second portions, wherein said patterned metal layer is connected to a first metal pad of said die through a first opening in said second polymer layer, and to a second metal pad of said die through a second opening in said second polymer layer, wherein said first metal pad is connected to said second metal pad through said patterned metal layer; and

a metal bump directly over said top surface of said first portion, wherein

said metal bump is connected to said die through said patterned metal layer.

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5        *Reconsiderations of Claims 179-196 rejected under 35 U.S.C. 103(a) as being unpatentable over Eichelberger et al. (U.S. Pat. No. 6,396,148) in view of Wagner et al. (U.S. Pat. No. 5,196,377) and Wachtler et al. (U.S. Pat. No. 6,707,124) are requested based on the following remarks.*

10        Applicants respectfully assert that the chip package currently claimed in Claim 179 patentably distinguishes over the citations by Eichelberger et al. (U.S. Pat. No. 6,396,148) in view of Wagner et al. (U.S. Pat. No. 5,196,377) and Wachtler et al. (U.S. Pat. No. 6,707,124).

15        The Examiner considers that “There is no need to insert any features from one reference into another to show obviousness.” ~ *See lines 4 and 5 on page 4, in the last Office Action mailed Jun. 17, 2008 ~*

20        Applicants respectfully traverse the Examiner’s opinion because there is believed to be a need of a test trying whether a feature from one reference is analogously inserted or incorporated into another feature from another reference based on the knowledge of one skilled in the art. Typically, analogous prima-facie cases are needed to support obvious rejection, with the explanation why the combination of these prima-facie cases is obvious by one skilled in the art.

25        The Examiner considers that “Regarding polymer interlevel dielectric layers, the prior art discloses polymer interlevel dielectrics, and again, insertion of one reference onto another is not required to show obviousness. For low capacitance and absent unexpected results, it would have been obvious to substitute one interlevel dielectric

material (polymer) for another known equivalent (oxide) as suggested by the applied art.”  
~ See lines 6-10 on page 4, in the last Office Action mailed Jun. 17, 2008 ~

5 Applicants respectfully traverse the Examiner’s opinion because there is believed to  
be a need of a test trying whether a feature from one reference is analogously inserted or  
incorporated into another feature from another reference based on the knowledge of one  
skilled in the art. Furthermore, the Examiner fails to show the exact description that one  
interlevel dielectric material (polymer) can be substituted for another known equivalent  
(oxide), in the applied art referred to by the Examiner.

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Furthermore, all of Eichelberger et al., Wagner et al. and Wachtler et al. fail to teach,  
hint or suggest that a patterned metal layer over a second polymer layer on two portions  
of a first polymer layer and on a die between the two portions may connect two metal  
pads of the die, as currently claimed in Claim 179.

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For at least the foregoing reasons, withdrawal of rejection under 35 U.S.C. 103(a)  
to Claim 179 is respectfully requested.

20 Applicants respectfully submit independent Claim 179 patently distinguishes over  
the prior art references, and should be allowed. For at least the same reasons, dependent  
Claims 180-196 patently define over the prior art as well.

#### **Response to Claims 197-208**

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As currently amended, independent Claim 197 is recited below:

197. A chip package comprising:  
a first polymer layer;

a die between a first portion of said first polymer layer and a second portion of said first polymer layer, wherein said die has a top surface substantially coplanar with a top surface of said first portion and with a top surface of said second portion;

a second polymer layer on said top surface of said die and on said top surfaces of said first and second portions;

a patterned metal layer over said second polymer layer, over said top surface of said die and over said top surfaces of said first and second portions, wherein said patterned metal layer comprises electroplated copper, and wherein said patterned metal layer comprises a ground bus connected to a first metal pad of said die through a first opening in said second polymer layer, and to a second metal pad of said die through a second opening in said second polymer layer, wherein said first metal pad is connected to said second metal pad through said ground bus; and

a metal bump directly over said top surface of said first portion, wherein said metal bump is connected to said die through said patterned metal layer.

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*Reconsiderations of Claims 197-208 rejected under 35 U.S.C. 103(a) as being unpatentable over Eichelberger et al. (U.S. Pat. No. 6,396,148) in view of Wagner et al. (U.S. Pat. No. 5,196,377) and Wachtler et al. (U.S. Pat. No. 6,707,124) are requested based on the following remarks.*

Applicants respectfully assert that the chip package currently claimed in Claim 197 patentably distinguishes over the citations by Eichelberger et al. (U.S. Pat. No. 6,396,148) in view of Wagner et al. (U.S. Pat. No. 5,196,377) and Wachtler et al. (U.S. Pat. No. 6,707,124).

The Examiner considers that “applicant’s argument regarding “electroplated copper” is unconvincing of patentability. Again it is emphasized there are no specific



copper structural differences claimed to distinguish the claimed copper over the copper of the applied art.” ~ *See lines 16-19, on page 3, in the last Office Action mailed Jun. 17, 2008* ~

5           Applicants respectfully traverse the Examiner’s opinion because “electroplated copper” can be expected to impart distinctive structural characteristics to the final product in the grain size using a TEM cross-section or in the crystal orientation using a TEM cross-section or an X-ray diffraction analysis. Furthermore, another structural feature that an electroplated copper layer is on or over an electroplating seed layer can be  
10   checked.

The Examiner considers that “There is no need to insert any features from one reference into another to show obviousness.” ~ *See lines 4 and 5 on page 4, in the last Office Action mailed Jun. 17, 2008* ~

15           Applicants respectfully traverse the Examiner’s opinion because there is believed to be a need of a test trying whether a feature from one reference is analogously inserted or incorporated into another feature from another reference based on the knowledge of one skilled in the art. Typically, analogous prima-facie cases are needed to support obvious  
20   rejection, with the explanation why the combination of these prima-facie cases is obvious by one skilled in the art.

The Examiner considers that “Regarding polymer interlevel dielectric layers, the prior art discloses polymer interlevel dielectrics, and again, insertion of one reference  
25   onto another is not required to show obviousness. For low capacitance and absent unexpected results, it would have been obvious to substitute one interlevel dielectric material (polymer) for another known equivalent (oxide) as suggested by the applied art.” ~ *See lines 6-10 on page 4, in the last Office Action mailed Jun. 17, 2008* ~

Applicants respectfully traverse the Examiner's opinion because there is believed to be a need of a test trying whether a feature from one reference is analogously inserted or incorporated into another feature from another reference based on the knowledge of one skilled in the art. Furthermore, the Examiner fails to show the exact description that one interlevel dielectric material (polymer) can be substituted for another known equivalent (oxide), in the applied art referred to by the Examiner.

Furthermore, all of Eichelberger et al., Wagner et al. and Wachtler et al. fail to teach, hint or suggest that a patterned metal layer over a second polymer layer on two portions of a first polymer layer and on a die between the two portions may comprises a ground interconnect connecting two metal pads of the die, as currently claimed in Claim 197.

For at least the foregoing reasons, withdrawal of rejection under 35 U.S.C. 103(a) to Claim 197 is respectfully requested.

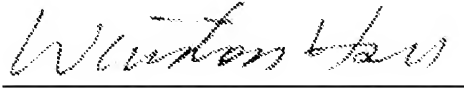
Applicants respectfully submit independent Claim 197 patently distinguishes over the prior art references, and should be allowed. For at least the same reasons, dependent Claims 198-208 patently define over the prior art as well.

#### CONCLUSION

Some or all of the pending claims are believed to be in condition for allowance. Accordingly, allowance of the claims and the application as a whole are respectfully requested.

Appl. No. 10/755,042  
Amdt. dated September 11, 2008  
Reply to Office action of June 17, 2008

Sincerely yours,



Date: 09.11.2008

Winston Hsu, Patent Agent No. 41,526

5 P.O. BOX 506, Merrifield, VA 22116, U.S.A.

Voice Mail: 302-729-1562

Facsimile: 806-498-6673

e-mail : winstonhsu@naipo.com

- 10 Note: Please leave a message in my voice mail if you need to talk to me. (The time in D.C. is 12 hours behind the Taiwan time, i.e. 9 AM in D.C. = 9 PM in Taiwan.)